



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Appl. No. : 10/823,607
Applicant : Albert Birner
Filed : April 14, 2004
TC/A.U. : 2822
Examiner : Thomas, T.
Confirmation No. : 5077
Docket No. : 3000.0052C
Customer No. : 054500
Title : A METHOD OF FORMING A SILICON DIOXIDE
LAYER

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

AMENDMENT

Sir:

In response to the Office Action mailed October 5, 2005, please amend the above-identified application as follows:

Amendments to the Claims are reflected in the listing of claims, which begins on page 2 of this paper.

Amendments to the Drawings begin on page 9 of this paper and include both attached replacement sheets and an annotated sheets showing changes made to Figures 10 and 11.

Remarks begin on page 10 of this paper.

An **Appendix** including annotated and replacement sheets and a replacement Abstract is attached starting at page 13 of this paper.

01/06/2006 SZEWDIE1 00000100 10823607

01 FC:1201 600.00 OP
02 FC:1202 100.00 OP